

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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| Applicant | : | Hada et al. |
| Appl. No. | : | 10/576,405 |
| Filed | : | April 30, 2007 |
| For | : | RESIST COMPOSITION AND METHOD FOR FORMING RESIST PATTERN |
| Examiner | : | Eoff, A. |
| Group Art Unit | : | 1795 |

AMENDMENT WITH RCE

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the final Office Action mailed **February 28, 2008**, please enter the following amendments and consider the following remarks.

Amendments to the Claims begin on page 2 of this paper.

Remarks begin on page 6 of this paper.